Serial No.: 09/841,156 Filed: April 25, 2001

Page : 2 of 16

Amendments to the Claims:

This listing of claims replaces all prior versions and listings of claims in the application:

Listing of Claims:

1-8. (Canceled)

9. (Currently Amended) A method of manufacturing a light emitting device, said method comprising the steps of:

forming a light emitting element at a front surface of a substrate;

polishing a back surface of the substrate by a chemical mechanical polishing method to thereby reduce a thickness of the substrate to less than 300 micrometers; and

bonding a color filter at the polished back surface of the substrate.

10. (Previously Presented) A method of manufacturing a light emitting device, said method comprising the steps of:

forming a semiconductor element and a light emitting element being electrically connected to the semiconductor element at a front surface of a substrate;

polishing a back surface of the substrate by a chemical mechanical polishing method; and bonding a color filter at the polished back surface of the substrate.

11. (Currently Amended) A method of manufacturing a light emitting device, said method comprising the steps of:

forming a <u>plurality of</u> light emitting <u>element</u> <u>elements in a matrix form</u> at a front surface of a first substrate; and

Serial No.: 09/841,156 Filed: April 25, 2001

Page : 3 of 16

bonding a transparent substrate comprising at least a colored layer at a back surface of the first substrate,

said method further comprising a step of bonding an antireflection film or a polarization plate to the transparent substrate.

12. (Currently Amended) A method of manufacturing a light emitting device, said method comprising the steps of:

forming a semiconductor element and a light emitting element being electrically connected to the semiconductor element at a front surface of a first substrate;

bonding a transparent substrate comprising at least a colored layer at a back surface of the first substrate,

said method further comprising a step of bonding an antireflection film or a polarization plate to the transparent substrate.

13. (Canceled)

14. (Original) A method according to claim 11, wherein the transparent substrate comprises a polymeric material.

15-16. (Canceled)

17. (Currently Amended) A method according to claim 11, further comprising the steps of:

polishing the back surface of the <u>first</u> substrate by a chemical mechanical polishing method.

18. (Canceled)

Serial No.: 09/841,156 Filed: April 25, 2001

Page : 4 of 16

19. (Original) A method according to claim 12, wherein the transparent substrate comprises a polymeric material.

20. (Currently Amended) A method according to claim 12, wherein the transparent substrate comprises a polymeric material further comprising the steps of:

polishing the back surface of the first substrate by a chemical mechanical polishing method.

21-22. (Canceled)

23. (Withdrawn): A method of manufacturing a light emitting device comprising: providing a first substrate having a first surface and a second surface opposite to said the first surface;

forming a first electrode over the first surface of the first substrate;

forming an electroluminescence layer over the first electrode; and

forming a second electrode over the electroluminescence layer so that said electroluminescence layer is interposed between said first and second electrodes over the first surface of the first substrate;

forming a plurality of color layers over a first surface of a second substrate;

fixing the second substrate to said first substrate with said plurality of color layers interposed therebetween, wherein said second substrate is located at a side of said second surface of the first substrate.

- 24. (Withdrawn) The method according to claim 23 wherein said light emitting device is a passive matrix display device.
- 25. (Withdrawn) The method according to claim 23 wherein said light emitting device is an active matrix display device.

Serial No..: 09/841,156 Filed : April 25, 2001

Page : 5 of 16

26. (Withdrawn) The method according to claim 23 wherein said electroluminescence layer comprises an organic electroluminescence material.

27. (Withdrawn) A method of manufacturing a light emitting device comprising: providing a first substrate having a first surface and a second surface opposite to said the first surface;

forming a first electrode over the first surface of the first substrate;

forming an electroluminescence layer over the first electrode; and

forming a second electrode over the electroluminescence layer so that said electroluminescence layer is interposed between said first and second electrodes over the first surface of the first substrate;

polishing the second surface of the first substrate to thin the first substrate;

forming a plurality of color layers over a first surface of a second substrate;

fixing the second substrate to the thinned first substrate with said plurality of color layers interposed therebetween, wherein said second substrate is located at a side of said second surface of the first substrate.

- 28. (Withdrawn) The method according to claim 27 wherein said light emitting device is a passive matrix display device.
- 29. (Withdrawn) The method according to claim 27 wherein said light emitting device is an active matrix display device.
- 30. (Withdrawn) The method according to claim 27 wherein said electroluminescence layer comprises an organic electroluminescence material.

Serial No.: 09/841,156 Filed: April 25, 2001

Page : 6 of 16

31. (Withdrawn) The method according to claim 27 wherein a thickness of said first substrate after the step of polishing is $300 \mu m$ or less.

32. (Withdrawn) A method of manufacturing a light emitting device comprising: providing a first substrate having a first surface and a second surface opposite to said the first surface;

forming a first electrode over the first surface of the first substrate;

forming an electroluminescence layer over the first electrode; and

forming a second electrode over the electroluminescence layer so that said electroluminescence layer is interposed between said first and second electrodes over the first surface of the first substrate;

providing a second substrate having a first surface and a second surface opposite to said second surface wherein said second substrate comprises a plastic material and each of the first and second surfaces of the second substrate are coated with a protective film;

forming a plurality of color layers over the second substrate;

fixing the second substrate to said first substrate with said plurality of color layers interposed therebetween, wherein said second substrate is located at a side of said second surface of the first substrate.

- 33. (Withdrawn) The method according to claim 32 wherein said light emitting device is a passive matrix display device.
- 34. (Withdrawn) The method according to claim 32 wherein said light emitting device is an active matrix display device.
- 35. (Withdrawn) The method according to claim 32 wherein said electroluminescence layer comprises an organic electroluminescence material.

Serial No.: 09/841,156 Filed: April 25, 2001

Page : 7 of 16

36. (Withdrawn) The method according to claim 32 wherein said protective film comprises diamond like carbon.

37. (Withdrawn) A method of manufacturing a light emitting device comprising: providing a first substrate having a first surface and a second surface opposite to said the first surface;

forming a first electrode over the first surface of the first substrate;

forming an electroluminescence layer over the first electrode;

polishing the second surface of the first substrate to thin the first substrate;

forming a second electrode over the electroluminescence layer so that said electroluminescence layer is interposed between said first and second electrodes over the first surface of the first substrate;

providing a second substrate having a first surface and a second surface opposite to said second surface wherein said second substrate comprises a plastic material and each of the first and second surfaces of the second substrate are coated with a protective film;

forming a plurality of color layers over the second substrate;

fixing the second substrate to the thinned first substrate with said plurality of color layers; interposed therebetween, wherein said second substrate is located at a side of said second surface of the first substrate.

- 38. (Withdrawn) The method according to claim 37 wherein said light emitting device is a passive matrix display device.
- 39. (Withdrawn) The method according to claim 37 wherein said light emitting device is an active matrix display device.
- 40. (Withdrawn) The method according to claim 37 wherein said electroluminescence layer comprises an organic electroluminescence material.

Serial No.: 09/841,156 Filed: April 25, 2001

Page : 8 of 16

41. (Withdrawn) The method according to claim 37 wherein a thickness of said first substrate after the step of polishing is 300 µm or less.

- 42. (Withdrawn) The method of claim 9 wherein the light emitting element comprises an electroluminescence material.
- 43. (Withdrawn) The method of claim 10 wherein the light emitting element comprises an electroluminescence material.
- 44. (Withdrawn) The method of claim 11 wherein the light emitting element comprises an electroluminescence material.
- 45. (Withdrawn) The method of claim 12 wherein the light emitting element comprises an electroluminescence material.
- 46. (New) The method according to claim 10, wherein a thickness of the substrate is less than 300 .m after the polishing step.
- 47. (New) A method of manufacturing a light emitting device, said method comprising the steps of:

forming a light emitting element at a front surface of a first substrate; and bonding a transparent substrate comprising at least a colored layer at a back surface of the first substrate,

said method further comprising a step of bonding an antireflection film to the transparent substrate.

Serial No.: 09/841,156 Filed: April 25, 2001

Page : 9 of 16

48. (New) The method according to claim 47, wherein the transparent substrate comprises a polymeric material.

- 49. (New) The method according to claim 47, further comprising the steps of: polishing the back surface of the first substrate by a chemical mechanical polishing method.
- 50. (New) A method of manufacturing a light emitting device, said method comprising the steps of:

forming a semiconductor element and a light emitting element being electrically connected to the semiconductor element at a front surface of a first substrate;

bonding a transparent substrate comprising at least a colored layer at a back surface of the first substrate,

said method further comprising a step of bonding an antireflection film to the transparent substrate.

- 51. (New) The method according to claim 50, wherein the transparent substrate comprises a polymeric material.
- 52. (New) The method according to claim 50, further comprising the steps of: polishing the back surface of the first substrate by a chemical mechanical polishing method.